

10 t=5 Δt 20 25

FIG.3

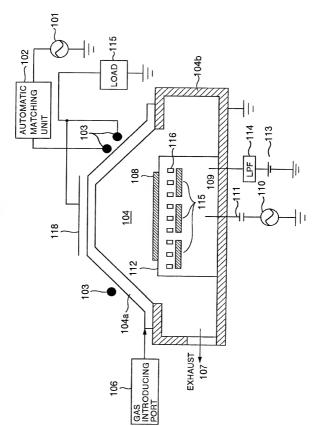


FIG.4A
BEFORE ETCHING

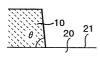


FIG.4B



FIG.4C

AFTER REMOVAL OF DEPOSITION MATERIAL



FIG.4D

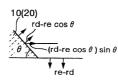


FIG.5A

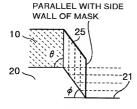


FIG.5B

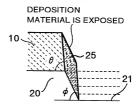


FIG.5C

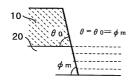


FIG.5D
MASK OR UNDERLYING

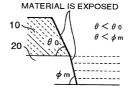
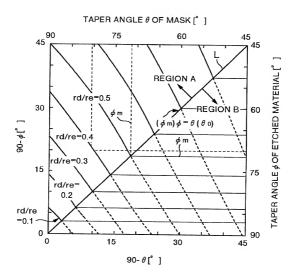
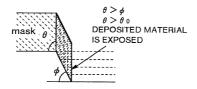


FIG.6



## FIG.7A

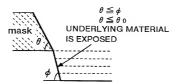
## REGION A



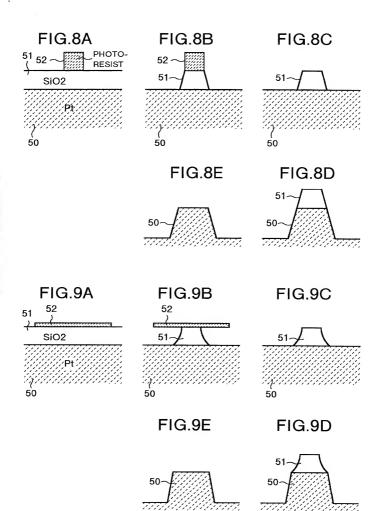
DEPOSITION MATERIAL ATTACHES TO MASK, TAPER ANGLE  $\phi$  OF ETCHED MATERIAL IS DETERMINED BY TAPER ANGLE  $\theta$  OF MASK

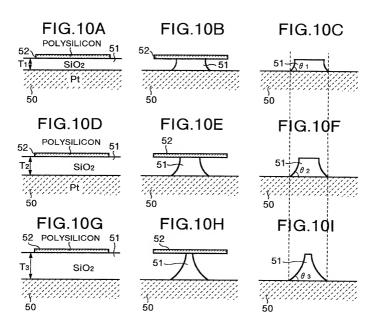
## FIG.7B

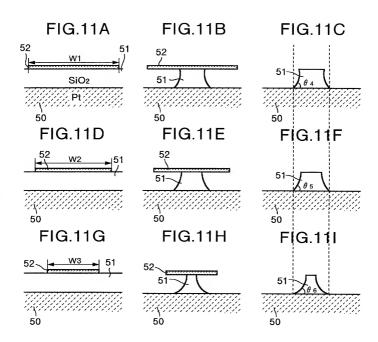
## REGION B

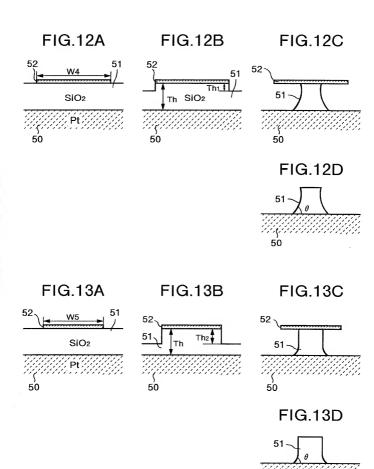


NO DEPOSITION MATERIAL ATTACHES TO MASK, TAPER ANGLE  $\phi$  OF ETCHED MATERIAL IS INDEPENDENT OF TAPER ANGLE  $\theta$  OF MASK









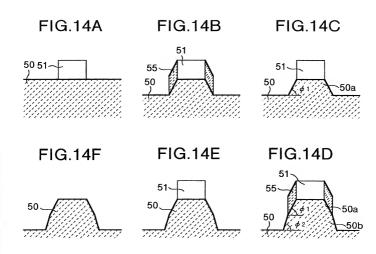


FIG.15A

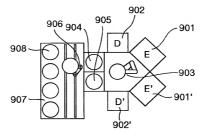


FIG.15B

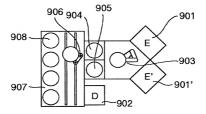
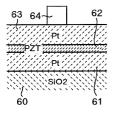
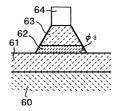


FIG.16A

FIG.16B

FIG.16C





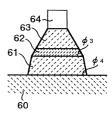


FIG.16D

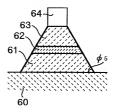


FIG.17A

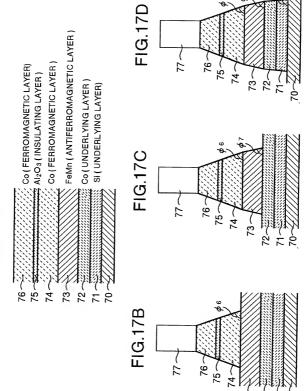


FIG.18

